

# Si-sensor tests

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# Contents

- **Motivation**
- **Measurement Set up**
- **Result**
  - **I-V curve**
  - **C-V curve**
- **Observation of gamma-ray signals**
- **Summary**
- **Prospects**

# Motivation

- ❑ **The Si-sensor (Silicon pixel sensor) would be the best for PFA.**
- ❑ **Kyushu University aims to be a center of the Si-ECAL study in Japan.**
- ❑ **It is very important to develop a system to examine many Si-sensor samples uniformly and efficiently in a same way.**



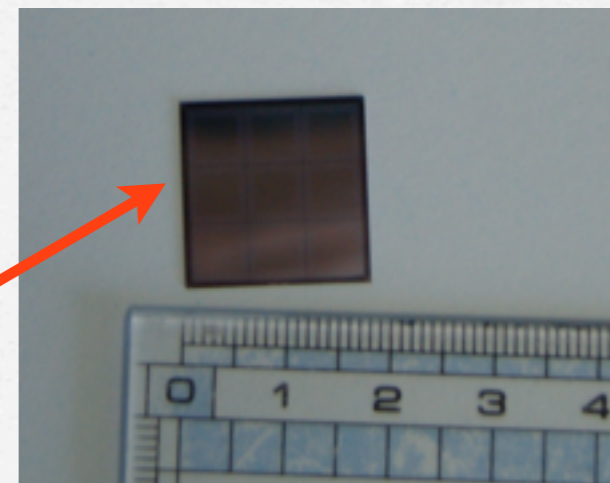
# Si-sensor samples

- **We measured five types of Si-sensors manufactured by HPK**
  - **mainchip (16×16 pixels)**
    - **type B (8.97×8.97 cm<sup>2</sup>) : 12 samples**
    - **type C (8.94×8.94 cm<sup>2</sup>) : 4 samples**
  - **babychip (3×3 pixels)**
    - **guard rings same as the mainchip Cut size C : 24 samples**
    - **split guard rings (4rings) Cut size B : 8 samples**
    - **split guard rings (4rings) Cut size C : 6 samples**



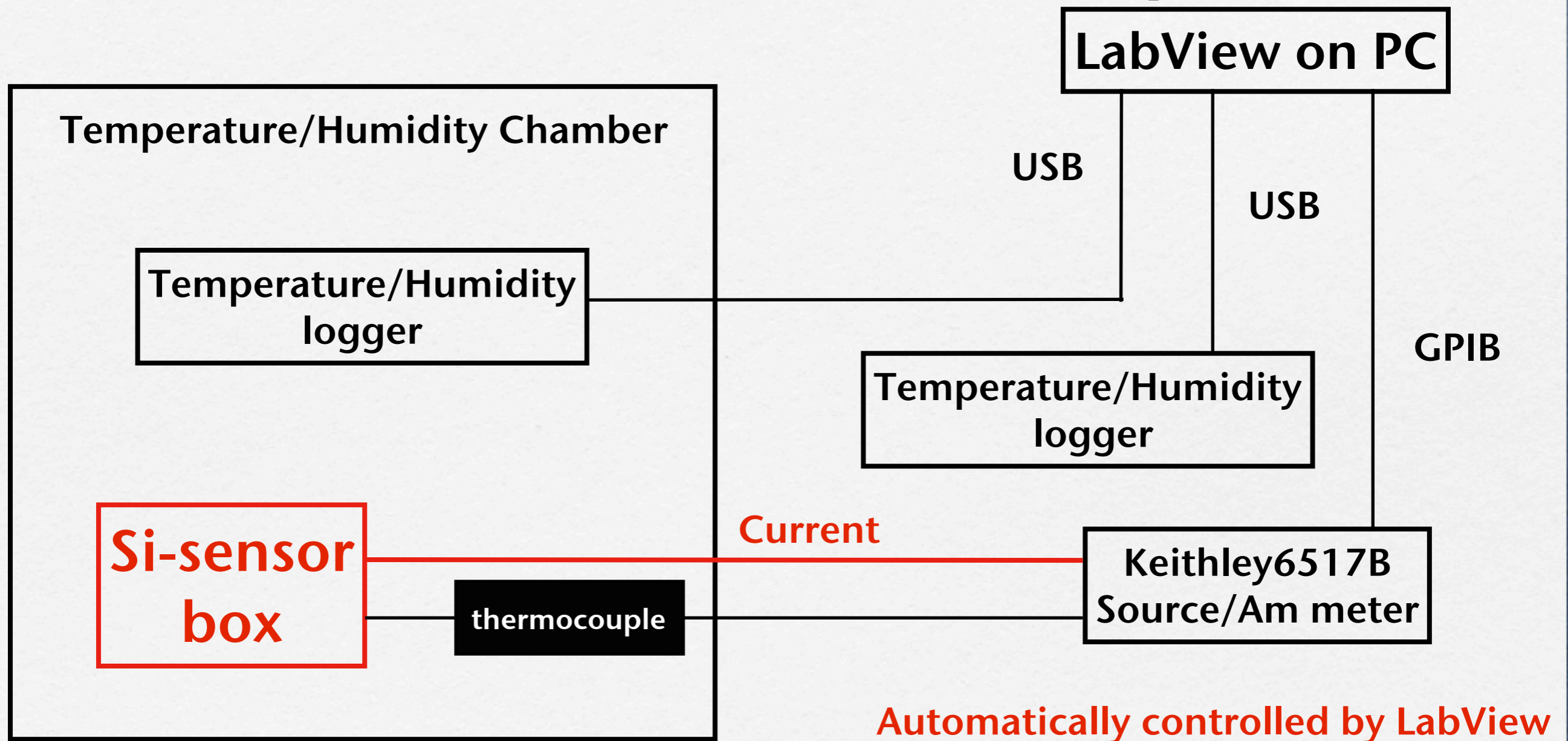
**mainchip**

**babychip**





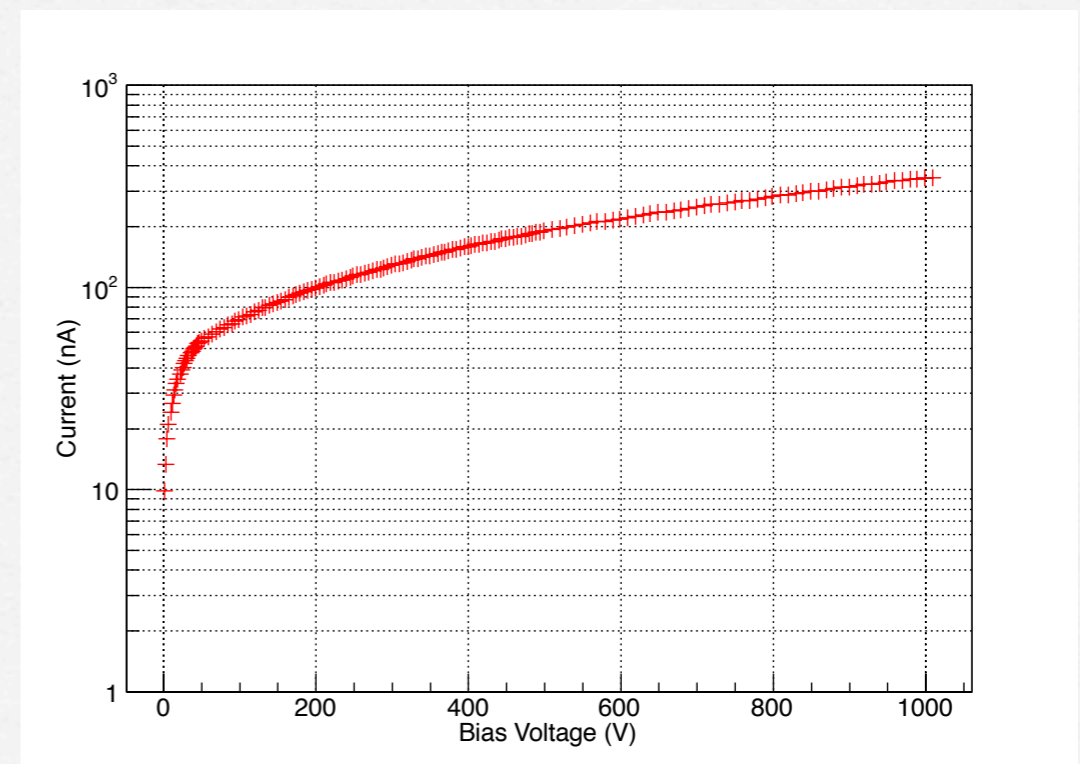
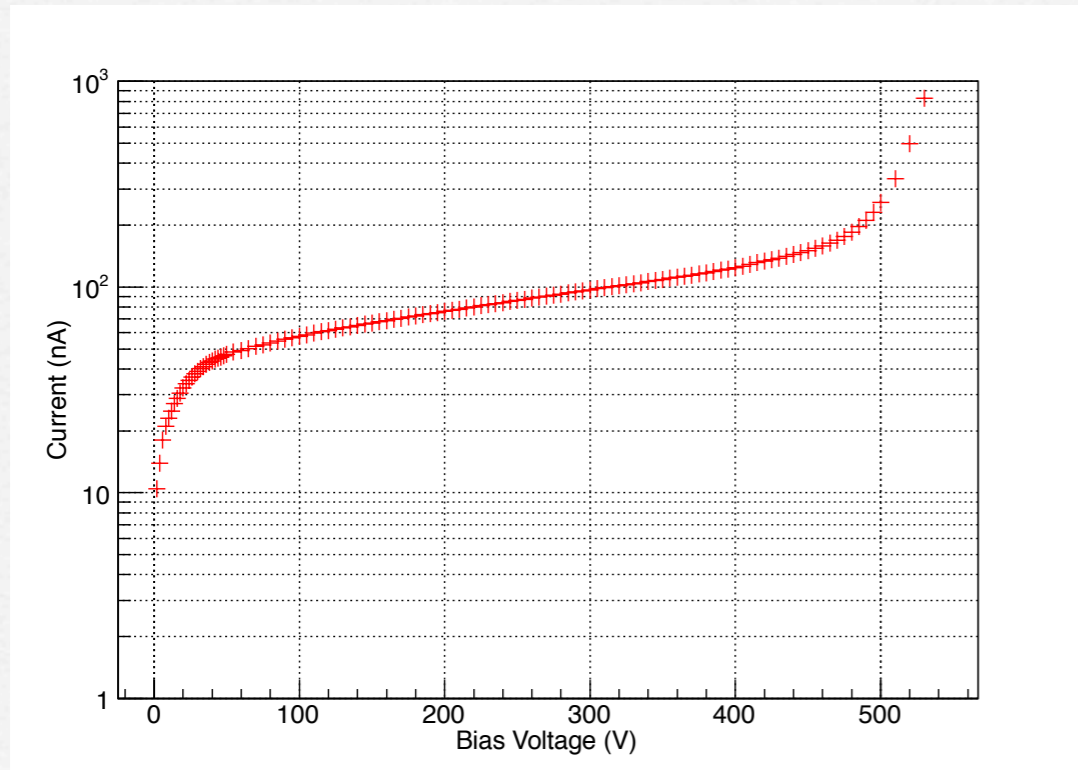
# I-V Measurement Setup



Thermocouple is installed in the box to directly monitor the Si-sensor's temperature

# I-V Measurement

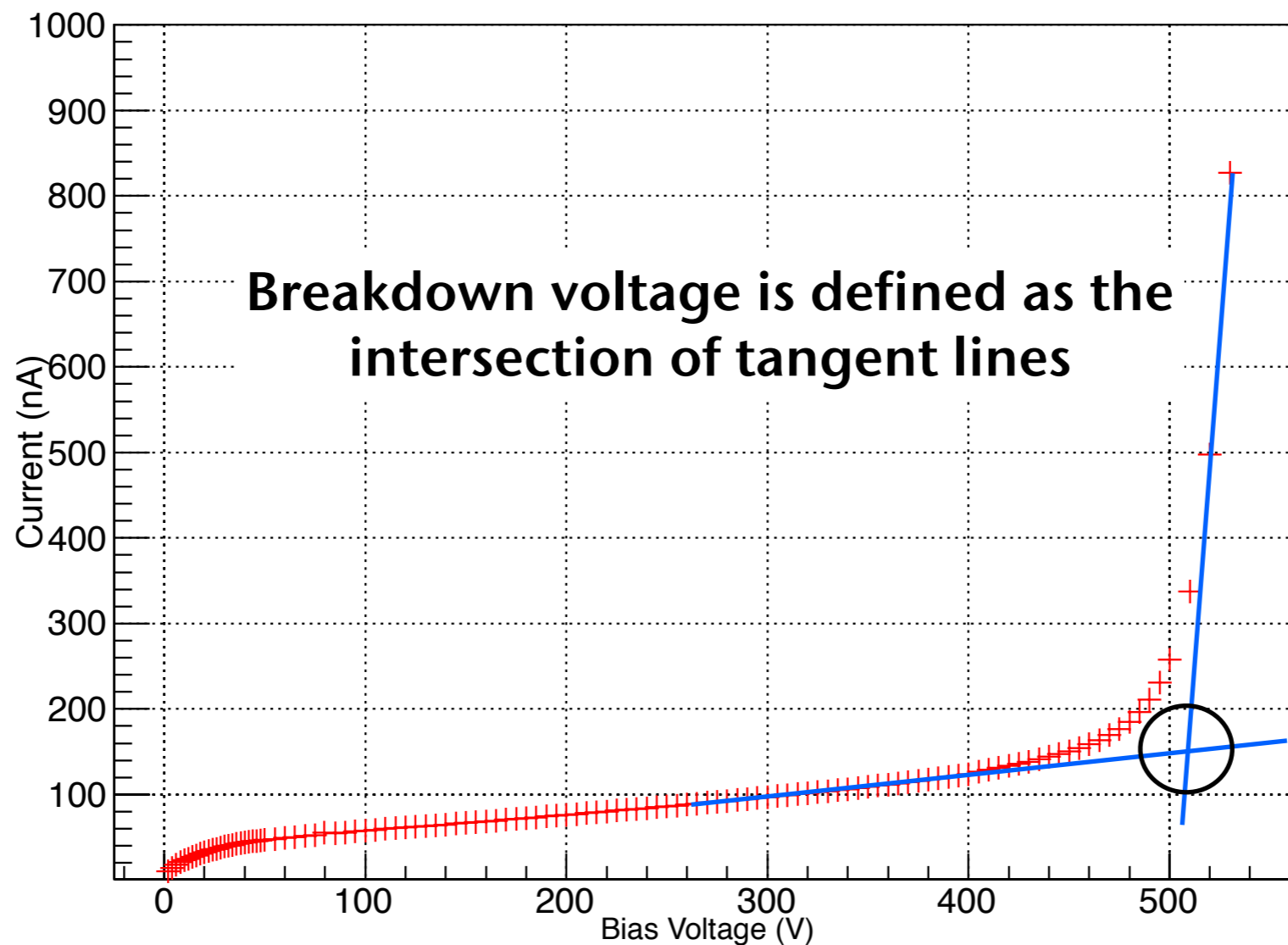
- **We measured the I-V curve for each sample at 20°C, 60% humidity**



**Breakdown occurs for some samples, but not for others.**



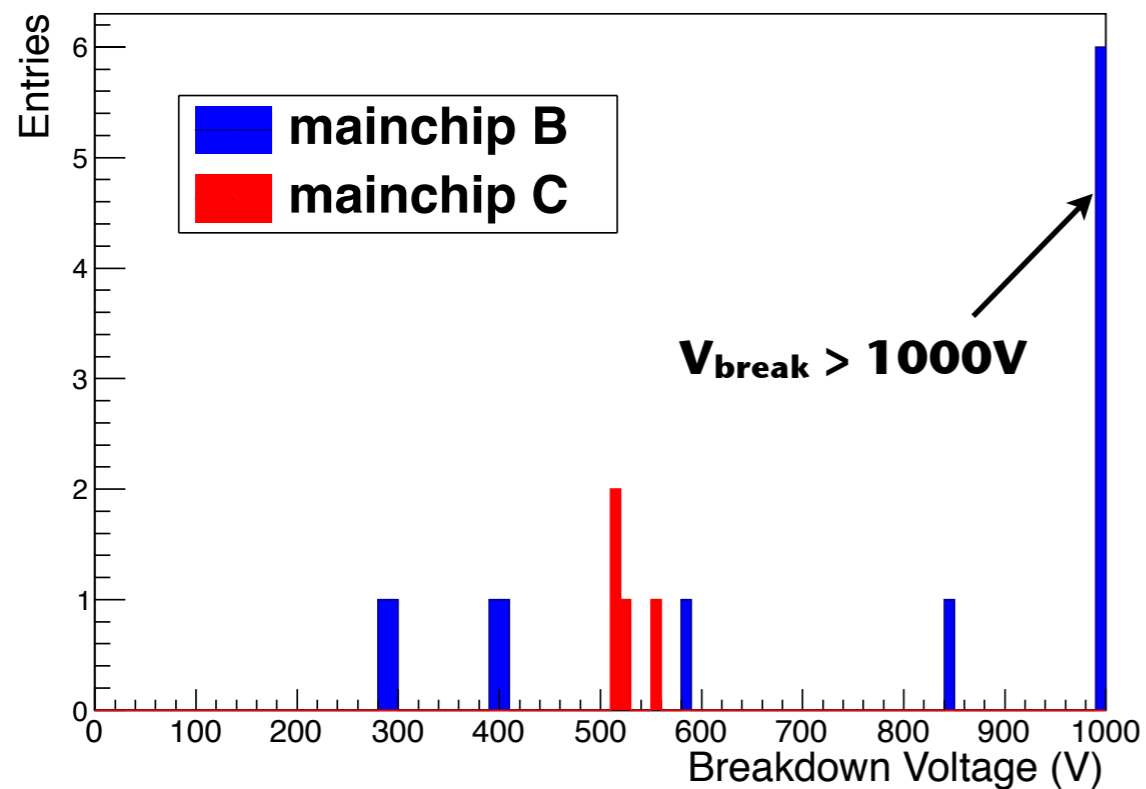
# I-V Measurement



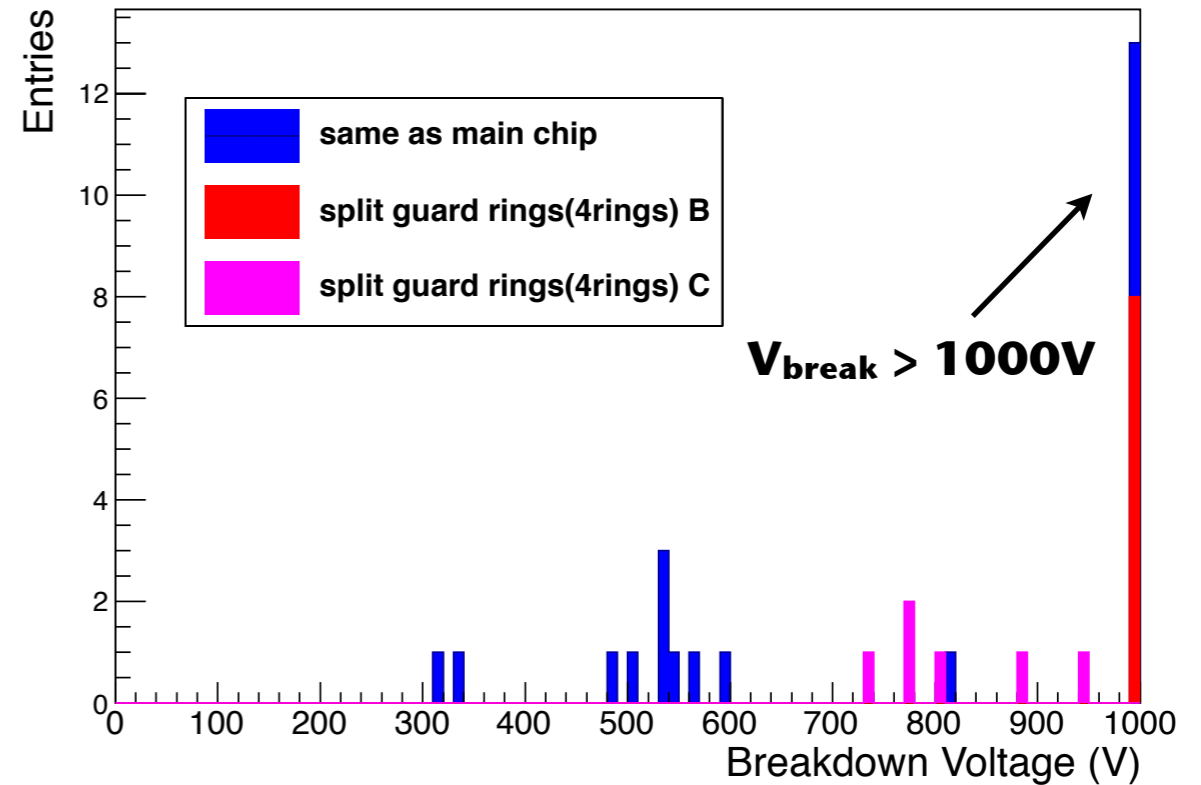
**We measured the breakdown voltage for each sample.**

# Breakdown Voltage

mainchip



babychip



**Samples in last bin don't reach breakdown voltage by 1000V.**

**We can operate all mainchips stably at  $V_{bias} < 300V$ .**

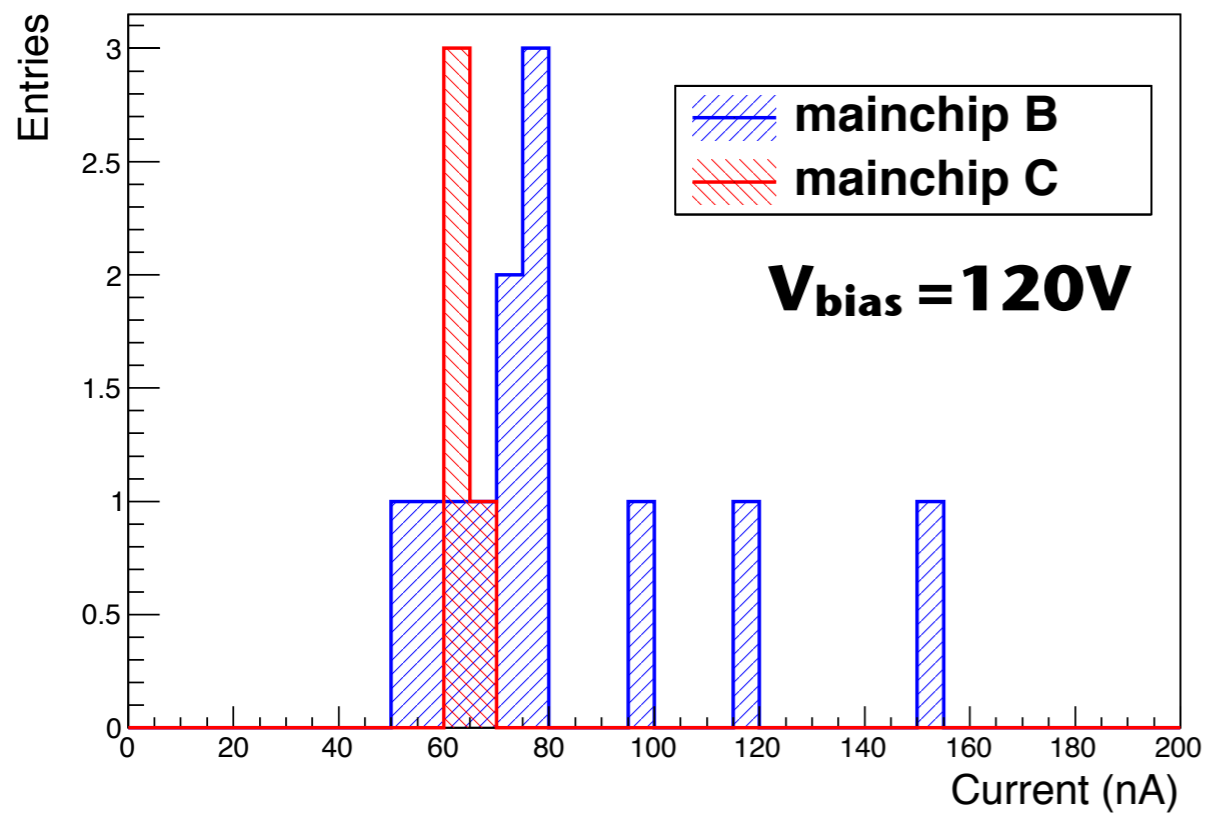
**Samples with split guard rings have larger breakdown voltage.**



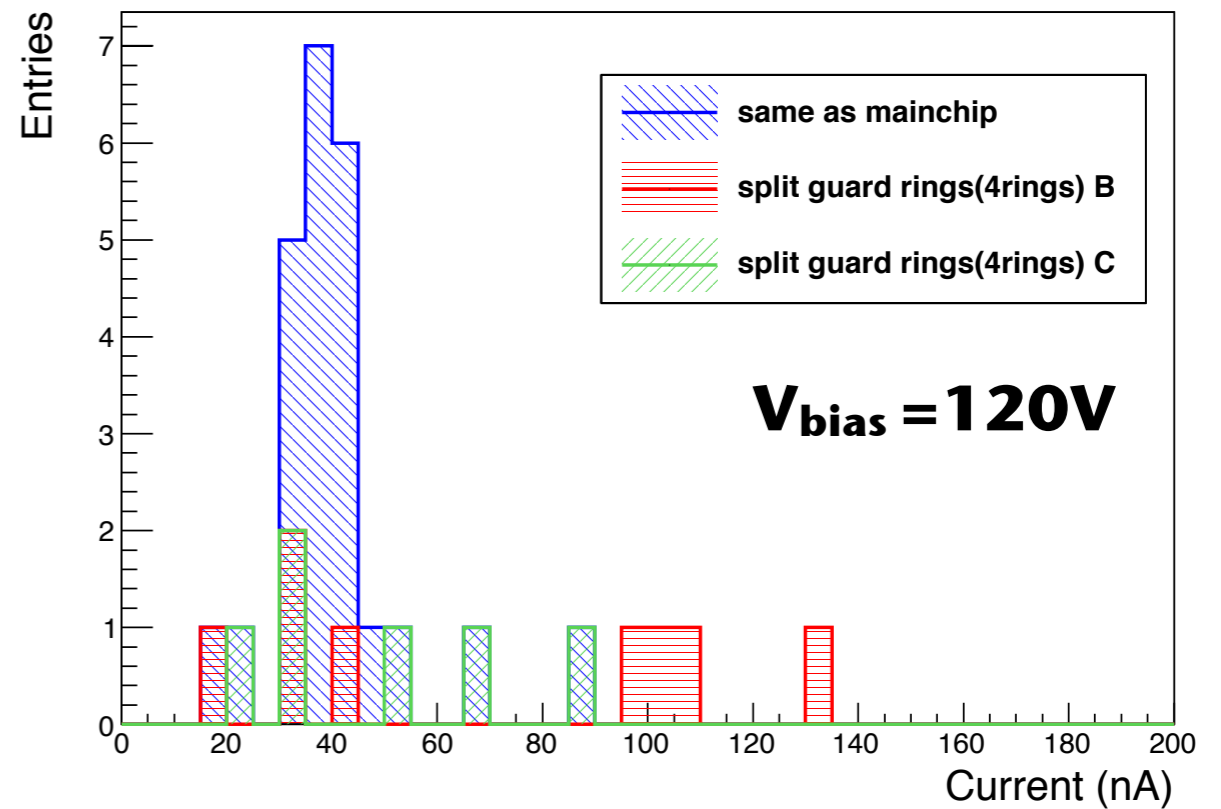
# Dark current at 120V

□ We measured the dark current at 120 V

Dark Current at 120V



Dark Current at 120V





# C-V Measurement

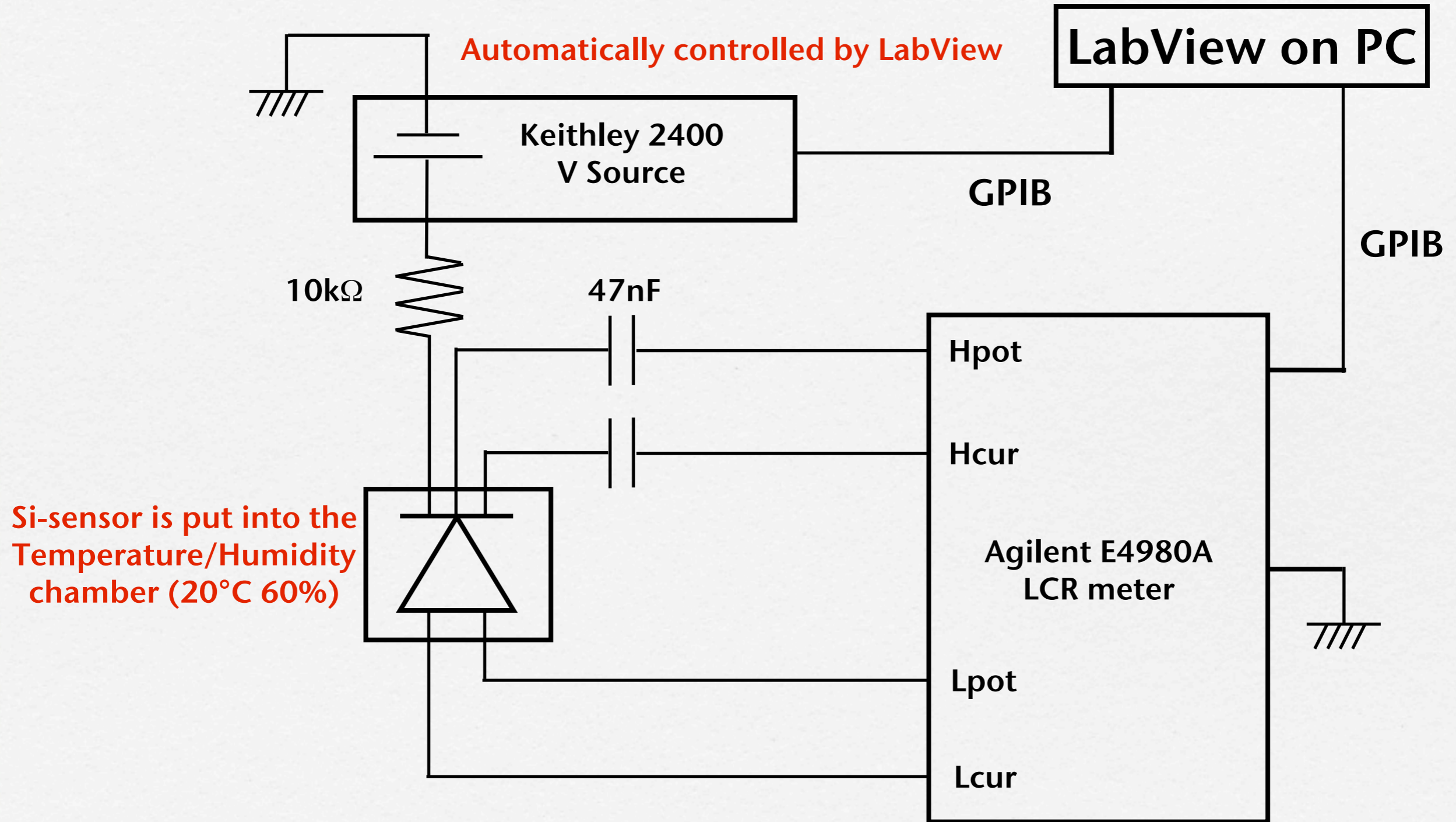
- ❑ **We measured the capacitance of all mainchips at 20°C, 60 % humidity.**
- ❑ **Increasing bias voltage, decreasing capacitance.**
- ❑ **As bias voltage reaches to full depletion voltage, capacitance becomes constant.**
- ❑ **Depth of the full Depletion region should be identical to thickness of the Si-sensor.**

$$C = \frac{\epsilon_{\text{si}} S}{d} \approx 2.4 \text{ nF}$$

$$d \approx 350 \mu\text{m}$$
$$\epsilon_{\text{si}} = 1.03 \times 10^{-10} \text{ F/m}$$



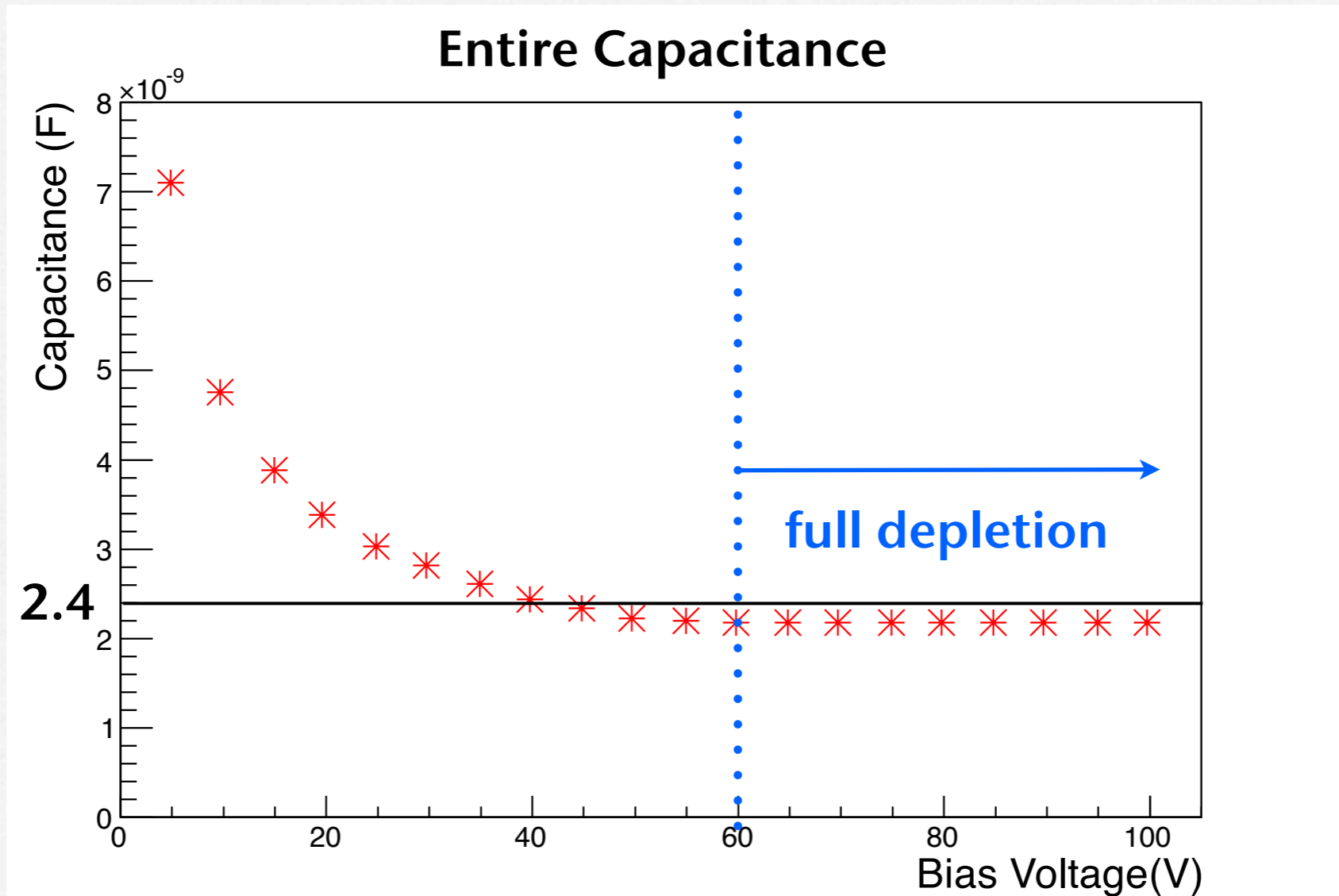
# C-V Measurement Setup



Changing the Voltage automatically, measure the capacitance



# Results



**Full depletion voltage of all mainchips distributed around 60V.**

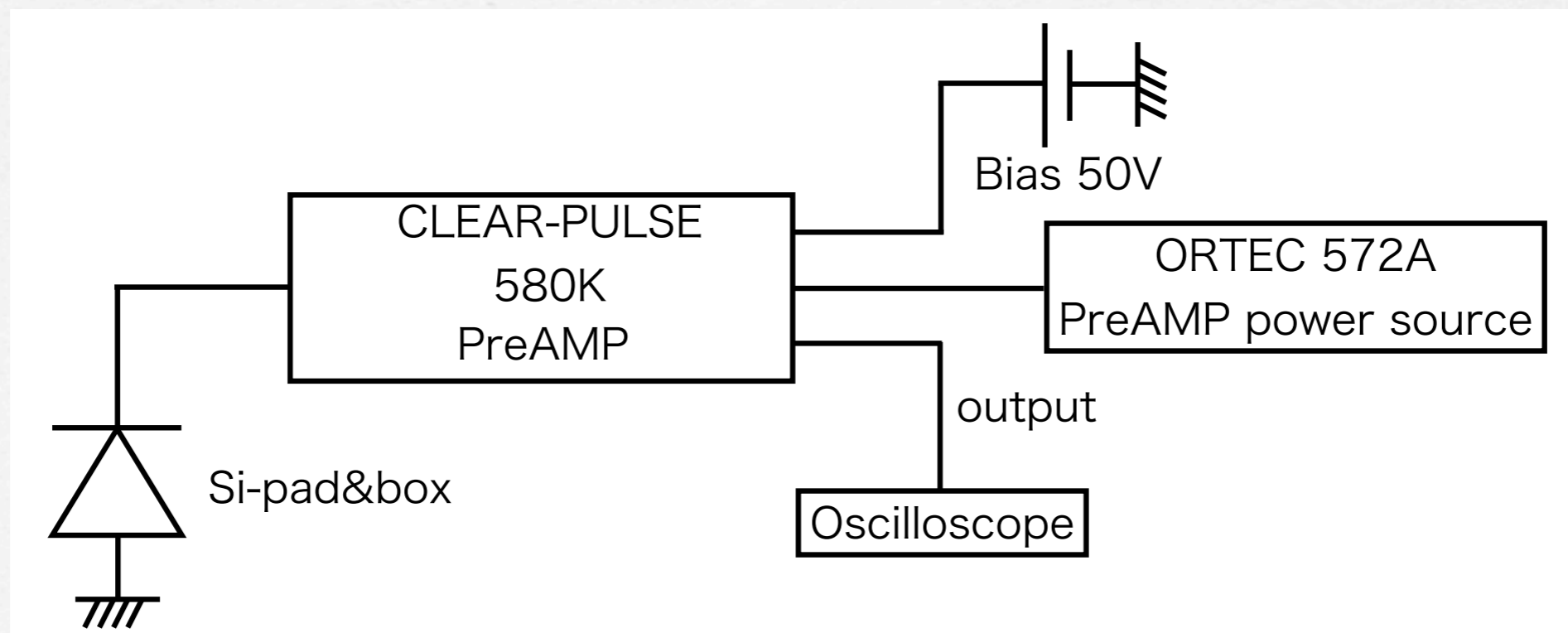


# Read out signals

- We made a signal read out system for total pixels.
- We observed gamma-ray signals ( $^{60}\text{Co}$ , 1.17MeV) using babychips
- Conversion coefficient of the PreAMP is 2V/pc
- Assuming that the ionization energy is 3eV, generated charge is

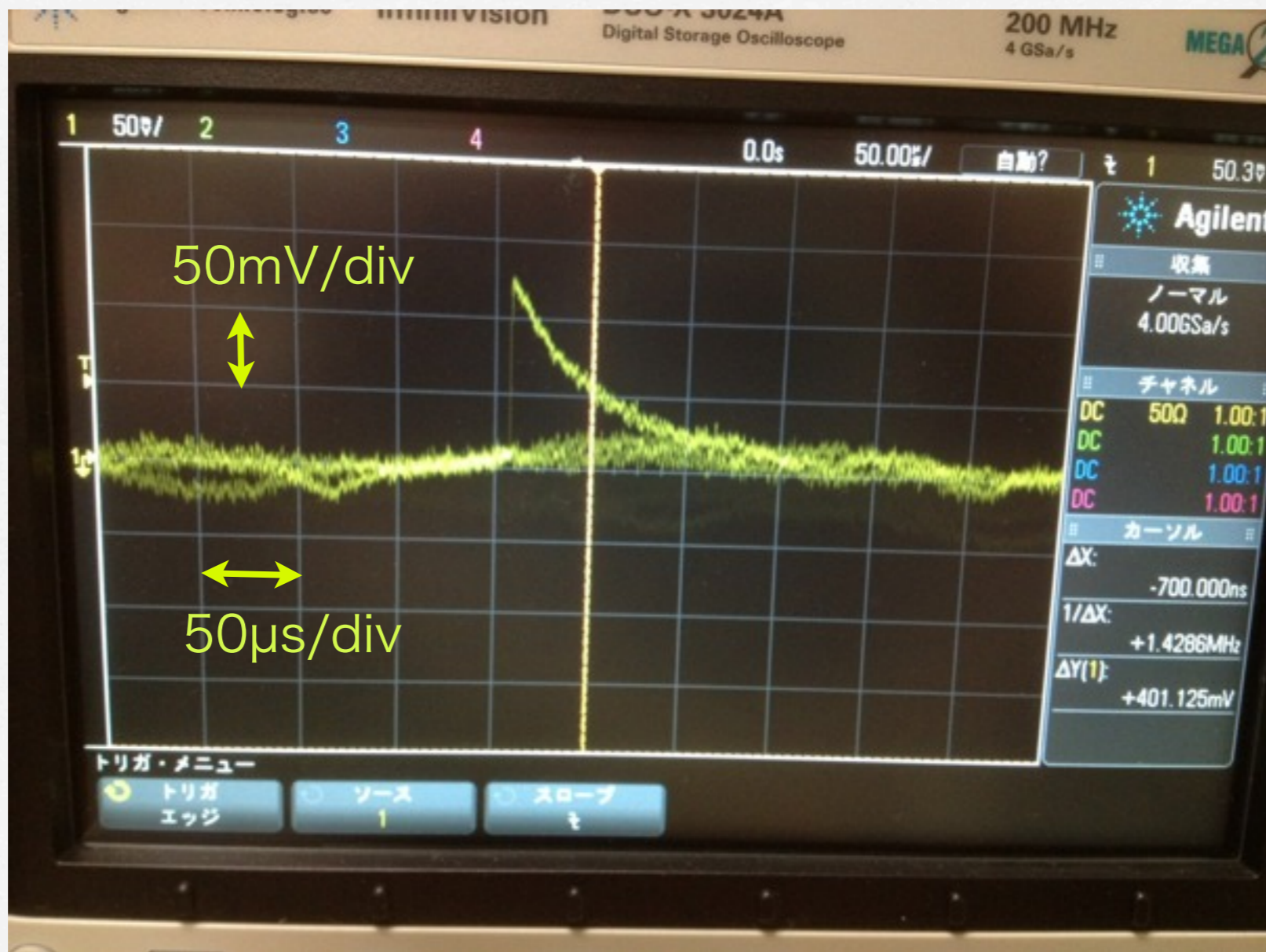
$$Q = 1.6 \times 10^{-19} \times (1.17\text{MeV}/3\text{eV}) = 0.0624\text{pC}$$

$$V = 0.0624 \times 2 = 124.8\text{mV}$$





# Signal Waveform



**We can observe gamma-ray signals, with large noise.**  
**We will try to reduce the noise.**



# Summary

- **We constructed automatic system to measure I-V curve and C-V curve.**
- **I-V curve**
  - **We can operate stably at  $V_{\text{bias}} < 300\text{V}$**
- **C-V curve**
  - **Full depletion occurs around 60V.**
- **Read out gamma-ray signals using a babychip**
  - **Signal observed, but noise was large**



# Prospects

## □ **C-V measurement**

- **1 pixel capacitance measurement.**

## □ **Signal test**

- **Improve measuring circuit.**
- **noise reduction.**
- **read out IR laser signals from 1 pixel.**
  - **to check crosstalk and behavior of sensor edge.**